



TOPCON电池去绕镀&RCA清洗设备

TOPCON Cell De-Plating & RCA Cleaning Equipment

特点描述

- 大产能设备，单次可处理6篮；
- 分布式盘管结合V型匀流板组成快速平稳的布液系统；
- 派单式手臂调度系统，实现生产工艺柔性化；
- 高效过滤与初效过滤相结合，很好的保证了设备内的洁净度；
- 高速稳定的机械手系统，负载≥100Kg。

Features

- High-capacity equipment, capable of processing 6 baskets at a time;
- Distributed coil & V type runner plate forms a high-efficiency liquid distribution system;
- Arm dispatch system, Achieve flexible production;
- Combining efficient filtration with preliminary filtration, ensure higher cleanliness inside the device;
- High speed and stable manipulator system, load ≥100Kg.

技术性能

产能: 16000片/小时 (每篮116片整片, 6篮/槽) ;
碎片率<0.3% (硅片厚度≥110um) ;
设备Uptime: ≥95%;
设备产品良率>99.9%。

Performance

Capacity: 16000 pcs/h (116 whole pieces per basket, 6 baskets/slots);
Breakage rate < 0.3% (Wafer thickness ≥ 110um);
Uptime: ≥ 95%;
Product yield > 99.9%.

技术参数 Parameter

项目 Item	数值 Value
清洗流程 Cleaning process	Alkline→PreCln→HF→Post1→DHF→DRY